CLBO - Cesium Lithium Borate (CsLiB₆O₁₀)

Introduction

Cesium Lithium Borate (CsLiB₆O₁₀ or CLBO) is a newly developed crystal with excellent UV nonlinear feature, and widely used for semiconductor inspection, micro processing, bio-medical, UV-LiDAR, etc. Compared to BBO, it has larger spectral and temperature acceptance, larger angle tolerance and smaller walk-off angle (see Table 1). These advantages make CLBO obtain larger SHG conversion efficiency than BBO. Moreover, it is suitable for FOHG and FIHG of high-power Nd:YAG laser.

CASTECH'S CLBO is featured by

- Cut-off wavelength up to 180 nm
- · Maximum FOHG and FIHG conversion efficiencies of Nd doped laser
- Relatively large effective NLO coefficient (about two times that of KDP)
- · Wide acceptance angle and small walk-off angle
- The VUV output at 193 nm is available by phase matching
- No saturation for high-power generation
- · Short grow cycle and large size

CASTECH offers

- Strict quality control
- Cutting angle and dimension upon request
- Sealed-housing or AR-coating/P-coating to prevent deliquescence
- AR-coating for fourth or fifth harmonic generations of 1064 nm
- Reworking services
- Fast delivery (15 working days for polished only, 20 working days for AR-coated)

Basic Properties

Table 1. Nonlinear Optical Properties of CLBO and BBO Crystal

Wavelength (nm)	NLO Crystal	Phase Matching Angle (deg)	Deff (pm/V)	Angle Tolerance (mrad·cm)	Walk-off Angle (deg)	Spectral Acceptance (nm·cm)	Temperature Acceptance (°C·cm)
532 + 532 = 266	CLBO	61.70	0.84	0.49	1.83	0.13	8.30
	BBO	47.70	1.32	0.17	4.80	0.07	4.50
1064 + 266 = 213	CLBO	68.40	0.87	0.42	1.69	0.16	4.60
	BBO	51.10	1.26	0.11	5.34	0.08	3.10

Table 2. Chemical and Structural Properties

Crystal Structure	Tetragonal, Space group I $\frac{1}{42}m$
Lattice Parameter	a = b = 10.494 Å, c = 8.939 Å
Symmetry	Z = 4
Melting Point	About 844.5 °C

Table 3. Optical and Nonlinear Optical Properties

Transparency Range	180-2750 nm		
Angle Acceptance	1.02 mrad·cm at 1064 nm, 0.49 mrad·cm at 532 nm, 0.84 mrad·cm at 488 nm.		
Temperature Acceptance	9.4°C·cm		
Spectral Acceptance	7.03 nm·cm at 1064 nm, 0.13 nm·cm at 532 nm, 0.09 nm·cm at 488 nm		
Walk-off Angle	$1.78\ ^{\circ}\ $ at 1064 nm, $1.83\ ^{\circ}\ $ at 532 nm, $0.98\ ^{\circ}\ $ at 488 nm		
Effective NLO Coefficients	1.01 pm/V at 532 nm, 1.16 pm/V at 488 nm, 0.95 pm/V at 1064 nm		
NLO Coefficients	$\begin{aligned} &d_{eff}(I) = d_{36} \sin \theta_m \sin(2 \; \Phi) \\ &d_{eff}(II) = d_{36} \sin(2 \; \theta_m) \sin(2 \; \Phi) \end{aligned}$		
Sellmeier Equations (λ in μm)	CLBO at 20 °C $n_o{}^2 = 2.2104 + 0.01018 / (\lambda^2 - 0.01424) - 0.01258 \lambda^2 \\ n_e{}^2 = 2.0588 + 0.00838 / (\lambda^2 - 0.01363) - 0.00607 \lambda^2 \\ (0.1914 \mu m < \lambda < 2.09 \mu m)$		

CLBO's Parameters

Table 4. Specifications

	1		
Dimension Tolerance	$(W \pm 0.1 \text{ mm}) \times (H \pm 0.1 \text{ mm}) \times (L + 0.5/-0.1 \text{ mm}) \times (L \ge 2.5 \text{ mm})$ $(W \pm 0.1 \text{ mm}) \times (H \pm 0.1 \text{ mm}) \times (L + 0.1/-0.1 \text{ mm}) \times (L < 2.5 \text{ mm})$		
Clear Aperture	Central 90% of the diameter		
Surface Quality (Scratch/Dig)	10/5 to MIL-PRF-13830B		
Flatness	≦λ/6 @633 nm		
Parallelism	20 arc sec		
Perpendicularity	≤ 15 arc min		
Angle Tolerance	$\Delta\theta \leq 0.25$ °, $\Delta\Phi \leq 0.25$ °		
Chamfer	≤0.2 mm × 45 $°$		
Chip	≦0.1 mm		
Damage Threshold	>300 MW/cm ² @532 nm, 10 ns, 10 Hz (AR-Coated); >150 MW/cm ² @266 nm, 10 ns, 10 Hz (AR-Coated);		
Quality Warranty Period	One year under proper use.		

Coatings

- Dual or triple band AR-coating of CLBO for fourth and fifth harmonic generation of 1064 nm
- · High damage threshold
- · Long durability
- Other coatings are available upon request

Table 5. Reflectance of AR-coating

Base Material	AR-Coating	Reflectance
CLBO	AR-532 nm/266 nm	R<0.2% @532 nm R<1% @266 nm
CLBO	AR-1064 nm/532 nm/266 nm	R<1.5% @ 1064 nm R<2% @ 532 nm R<2% @ 266 nm
CLBO AR-1064 nm/266 nm/213 nm		R<1.5% @ 1064 nm R<2% @ 266 nm R<2% @ 213 nm

Notes

CLBO crystal is very hygroscopic, and please use or keep it in dry and sealed environment.